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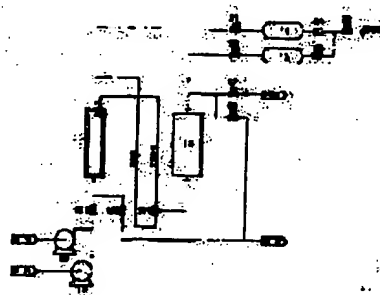
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(54) ON-LINE CHEMICAL CLEANING METHOD FOR FILTER MEMBRANE MODULE

(57)Abstract:

PROBLEM TO BE SOLVED: To provide an on-line chemical cleaning method for cleaning a filter membrane module efficiently in a filtration apparatus using a filter membrane provided with the filter membrane module.

SOLUTION: In the on-line chemical cleaning method for the filter membrane module, the module is physically washed in advance of chemical cleaning. After the physical washing, the module is drained, and the module is chemically cleaned. The module is further physically washed, and then the module is drained.



LEGAL STATUS

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